

**FABRIC SURFACE AREA MEASUREMENT  
USING 3D PROFILOMETRY**



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## INTRODUCTION:

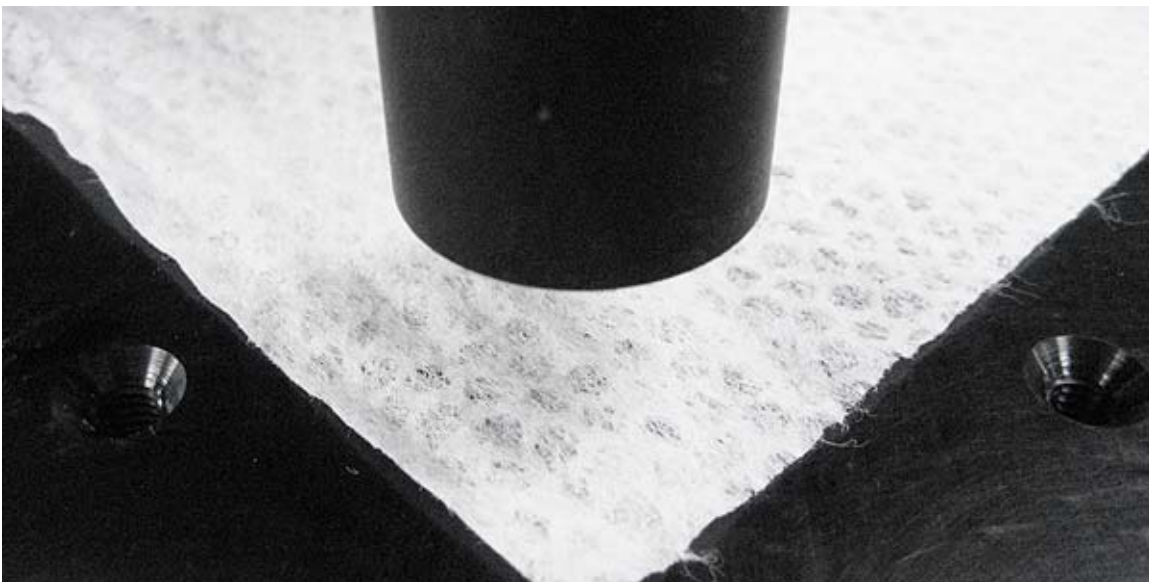
Surface area measurement can be critical when studying the intended interaction of fabric cleaning supplies on various types of surfaces. Projected and developed surface areas of cleaning supplies can translate into superior absorbency of germs and other unfavorable residues. The developed surface area is not the only contributing factor to its efficiency. For example, the unique pattern found on the surface of cleaning wipes is intended to increase the effectiveness of its use.

### IMPORTANCE OF 3D NON CONTACT PROFILOMETER FOR SURFACE AREA ANALYSIS

The Nanovea 3D Non-Contact Profilometer is ideal for measuring the surface of a cleaning wipe with its use of axial chromatism. The technique provides measurement on nearly any surface, sample sizes can vary widely due to open staging and there is no sample preparation needed. The Nanovea 3D Non-Contact Profilometer has the advanced ability to measure high surface angles without software manipulation of results. Easily measure any material, such as transparent, opaque, specular, diffusive, polished, rough, etc. Techniques such as touch probes and other non-contact techniques would have difficulties properly measuring the fabric surface of a cleaning wipe. The technique of the 3D Non-Contact Profilometer provides an ideal, broad, and user friendly capability to maximize studies of unique surfaces such as fabric cleaning wipes.

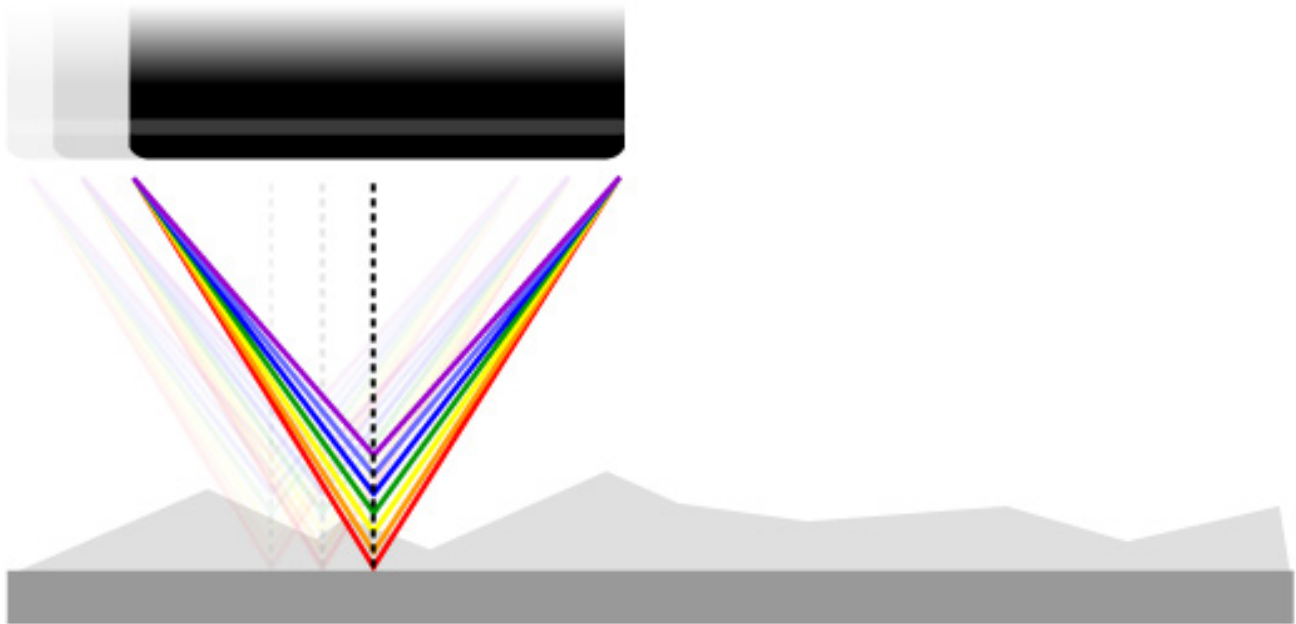
### MEASUREMENT OBJECTIVE

In this application the Nanovea ST400 Profilometer was used to measure the surface area of a fabric cleaning wipe to determine amount of projected and developed surface areas as well as a contour analysis of the texture on the surface.



## MEASUREMENT PRINCIPLE:

The axial chromatism technique uses a white light source, where light passes through an objective lens with a high degree of chromatic aberration. The refractive index of the objective lens will vary in relation to the wavelength of the light. In effect, each separate wavelength of the incident white light will re-focus at a different distance from the lens. When the measured sample is within the range of possible heights, a single monochromatic point will be focused to form the image. Due to the confocal configuration of the system, only the focused wavelength will pass through the spatial filter with high efficiency, thus causing all other wavelengths to be out of focus. The spectral analysis is done using a diffraction grating. This technique focuses each wavelength at a different position, intercepting a line of CCD, which in turn indicates the position of the maximum intensity and allows direct correspondence to the Z-height position.

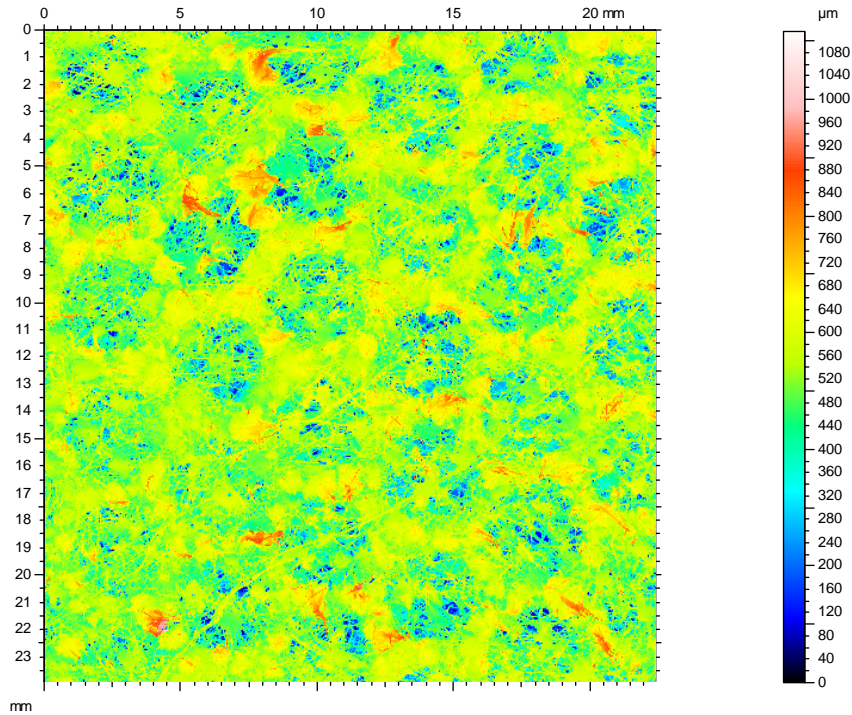


Unlike the errors caused by probe contact or the manipulative Interferometry technique, White light Axial Chromatism technology measures height directly from the detection of the wavelength that hits the surface of the sample in focus. It is a direct measurement with no mathematical software manipulation. This provides unmatched accuracy on the surface measured because a data point is either measured accurately without software interpretation or not at all. The software completes the unmeasured point but the user is fully aware of it and can have confidence that there are no hidden artifacts created by software guessing. Nanovea optical pens have zero influence from sample reflectivity or absorption. Variations require no sample preparation and have advanced ability to measure high surface angles. Capable of large Z measurement ranges. Measure any material: transparent/opaque, specular/diffusive, polished/rough.

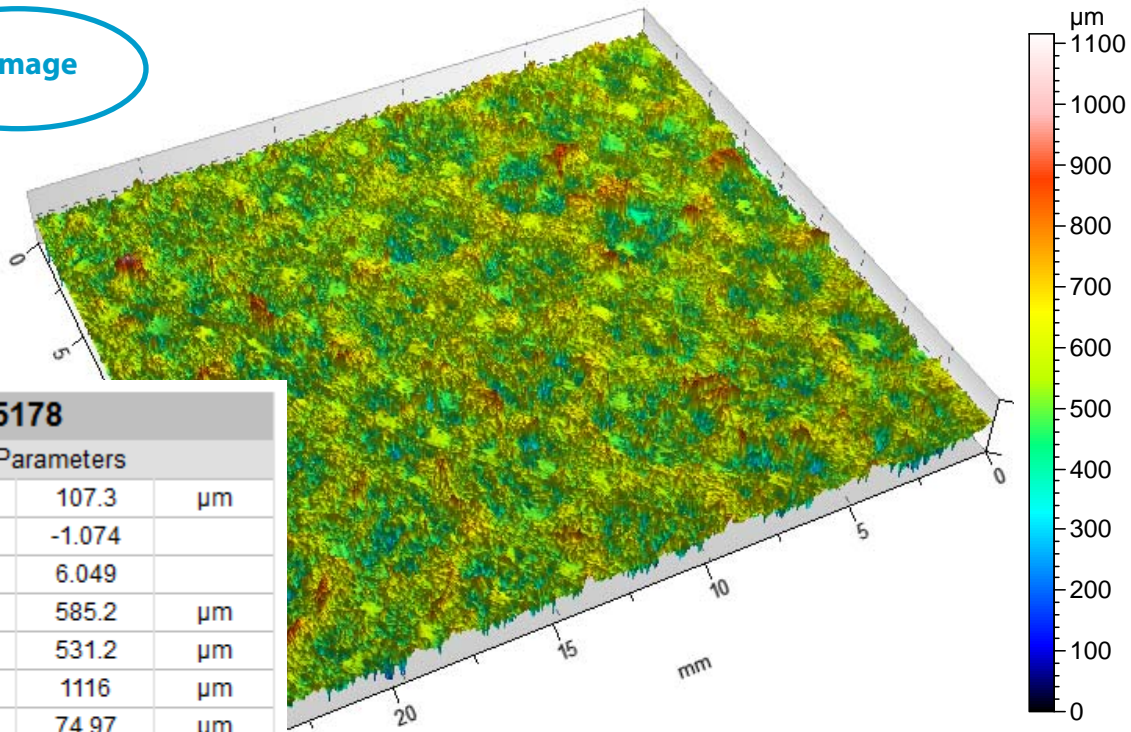
## RESULTS: Projected Surface Area and Developed Surface Area (Cleaning Wipe)

Parameters Used: X- Scan Length: 30.0mm, Scan Step Size: 12.0 $\mu$ m, Pen Settings Pen: 1.2mm, Acquisition Rate: 180Averaging: 1

False Color View



3D Image

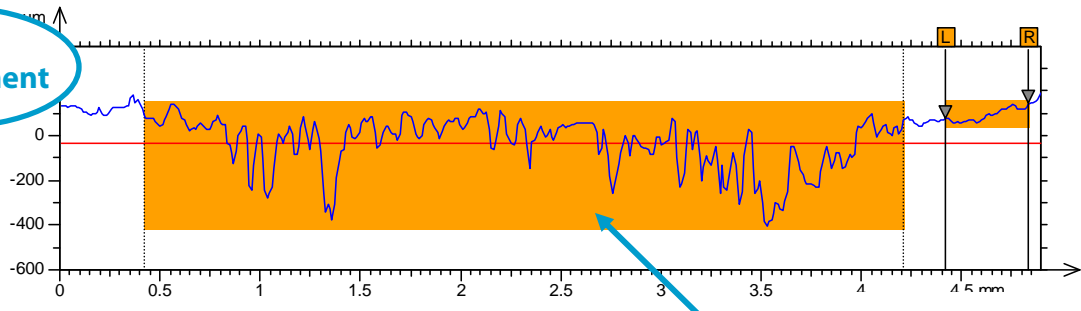


ISO 25178		
Height Parameters		
Sq	107.3	$\mu$ m
Ssk	-1.074	
Sku	6.049	
Sp	585.2	$\mu$ m
Sv	531.2	$\mu$ m
Sz	1116	$\mu$ m
Sa	74.97	$\mu$ m
Other 3D Parameters		
Miscellaneous		
Sdar	5080	mm <sup>2</sup>
Spar	535.8	mm <sup>2</sup>

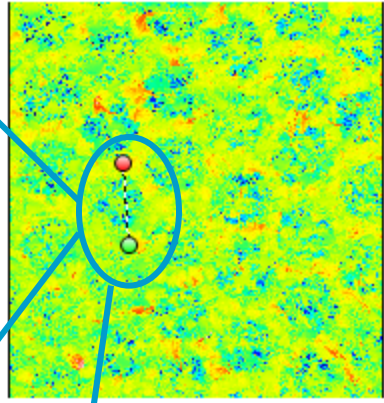
Developed Surface Area

Projected Surface Area

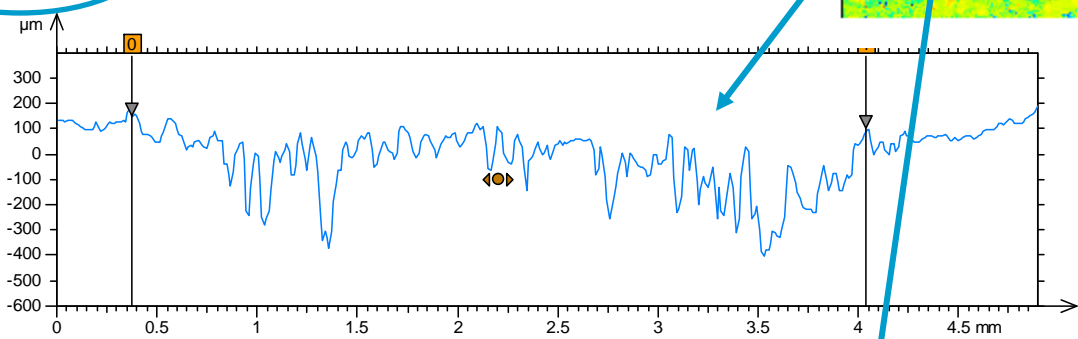
**Depth Measurement**



Maximum height **181.3  $\mu\text{m}$**   
 Mean height **129.8  $\mu\text{m}$**

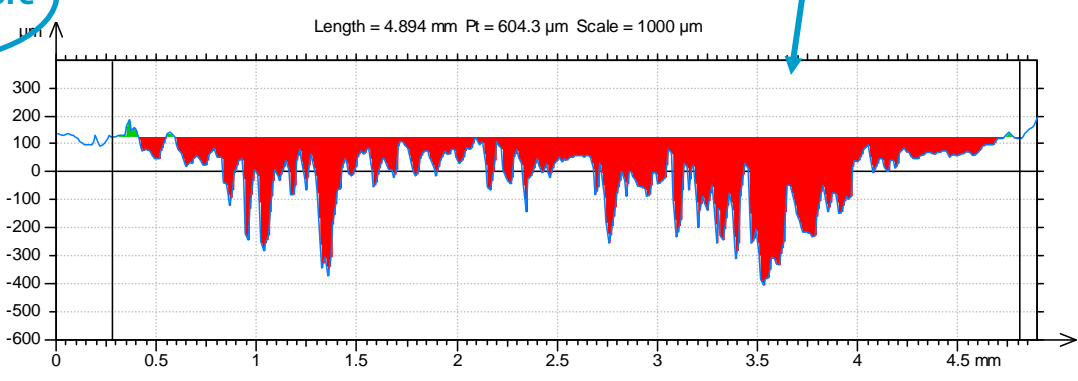


**Distance Measurement**

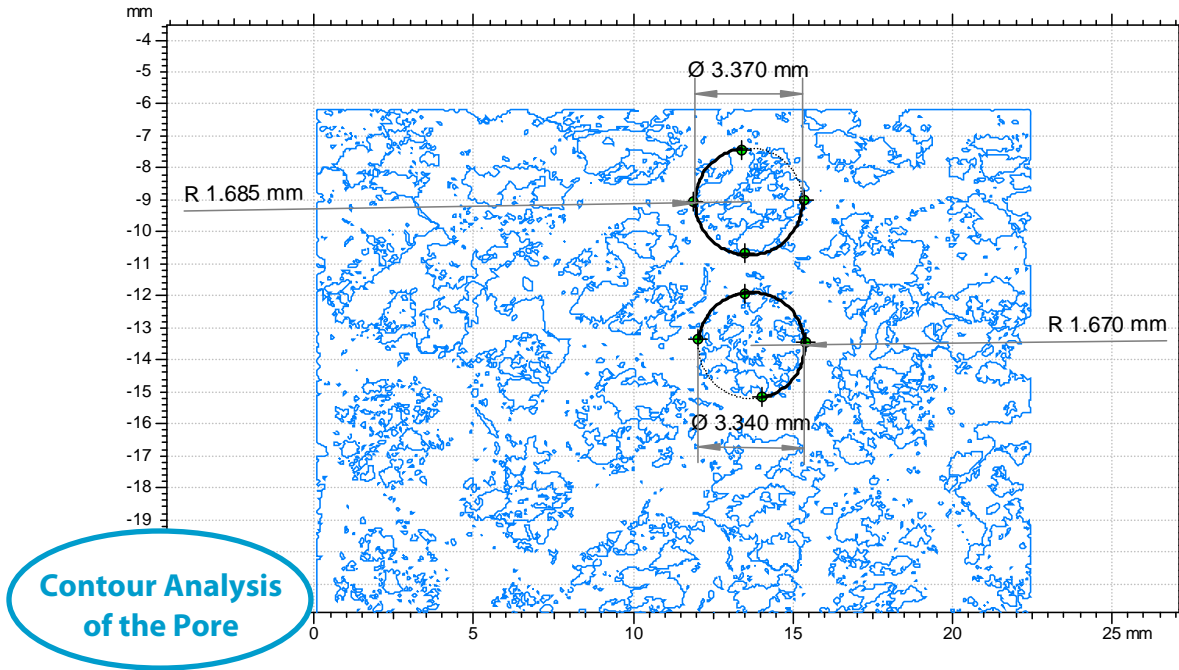


Horizontal distance **3.669 mm**

**Area of the Pore**



Maximum depth **0.5354 mm** Area of the hole **0.6499 mm<sup>2</sup>**



## CONCLUSION:

In this application, using the Nanovea 3D Non Contact Profilometer, we have shown how the surface area increased with the honeycomb fabric design on the surface of the wipe. The developed area increased by approximately ten times the projected area. Other than the measurements shown here, the 3D No Contact Profilometer has an endless range of measurements (Dimension, Roughness Finish Texture, Shape Form Topography, Flatness Warpage Planarity, Volume Area, Step-Height Depth Thickness and others). With this information projected and developed surface areas can be broadly investigated with a complete set of surface measurements. To learn more about the [Nanovea Profilometer](#)